

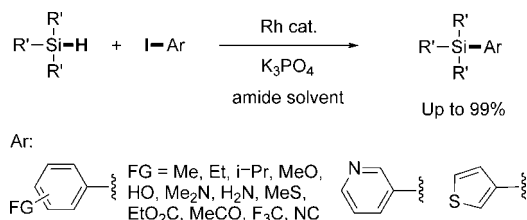
Direct and Selective Arylation of Tertiary Silanes with Rhodium Catalyst

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We have developed a convenient and efficient approach to the arylation of tertiary silanes under mild conditions. A variety of arylsilanes were synthesized in a one-step process with good to excellent yields in the presence of a rhodium catalyst with a base. The reaction was highly solvent dependent, and amides were the most effective of the various solvents used. This common catalyst system is highly tolerant of the various sensitive functional groups on the substrates, which might be difficult to extract by other methods. The rhodium-promoted silylation of aryl halides with electron-donating groups occurred more efficiently than the silylation of aryl halides substituted with electron-withdrawing groups. Heteroaromatic halides were also found to be readily silylated with tertiary silanes. The successful application of this reaction to the synthesis of a TAC-101 analogue, which is a trialkylsilyl-containing synthetic retinoid benzoic acid derivative with selective binding affinity for retinoic acid receptor- α , is also described.

Introduction

Arylsilanes and their derivatives have been widely studied in material science for their unique properties. Recently, these compounds have been discussed as potential candidates as intermediates for Hiyama coupling,¹ organic phosphorescent materials,² and medicinal products.³ For this reason, the efficient synthesis and functionalization of arylsilane derivatives have

attracted the interest of many synthetic chemists. Although arylsilanes have been classically prepared by the reaction of Grignard or with organolithium reagents with silicon electrophiles,⁴ these protocols lack wide applicability; however, an efficient synthesis of functionally substituted arylsilanes has been elusive.

Transition metal-catalyzed C–C coupling reactions have been recognized as powerful tools in multiple organic transformations.⁵ Transition metal-catalyzed C–Si bond-forming reactions are also potent methods for the preparation of arylsilanes, and

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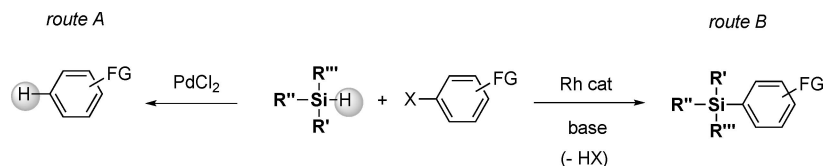
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SCHEME 1. Direct Arylation of Tertiary Silanes



several examples of synthesis with transition metal catalysts have been reported. The silylation of aromatic C–H bonds is the most straightforward and atom-economical route to arylsilane derivatives.⁶ However, only limited protocols have been reported in the literature. The reaction usually requires a long reaction time and high temperatures (often above 150 °C), has a low yield, and is limited by the small range of potential starting materials.

Generally, hydrosilanes have been widely used as mild reducing reagents for fine organic syntheses.⁷ Since the pioneering work of Murata et al., Manoso and DeShong, Denmark and Kallemeyn, Komuro et al., and Ito, transition metal-catalyzed cross-coupling reactions of aryl halides with trialkoxysilane have emerged as an alternative and promising method for Si–C bond formation.⁸ This method has received much attention because it can produce important synthetic building blocks that are difficult to prepare with other technologies. However, in most cases trialkylsilanes were not suitable silylating reagents because of their strong reducing power toward aryl halides in the presence of catalyst.⁹ For example, Chatgililoglu et al. reported that the addition of a catalytic amount of palladium dichloride to a mixture of 4-iodoanisole and triethylsilane in ether at room temperature exclusively produced the corresponding reduction product, anisole (Scheme 1, route A).¹⁰ In the course of our study of the synthetic use of trialkylsilanes, we recently reported

the palladium- and rhodium-catalyzed cross coupling of trialkylsilanes with aryl iodides under mild conditions with good to high yields.^{11,12} In the present work, the scope and limitations of this silylation are evaluated by testing a wide variety of aryl halides and tertiary silanes reacted with a rhodium catalyst (Scheme 1, route B). The application of silylation to the total synthesis of a TAC-101 analogue,¹³ a synthetic retinobenzoic acid with selective binding affinity for retinoic acid receptor (RAR)- α ,¹⁴ is also demonstrated.

Results and Discussion

Rhodium-Catalyzed Arylation of Tertiary Silane. To demonstrate the feasibility of rhodium-catalyzed arylation of a tertiary silane, we examined the triethylsilylation of 2-iodoanisole (**1a**) using a series of catalysts, bases, and solvents, as summarized in Table 1. As we reported previously, the palladium-catalyzed reaction of a sterically hindered ortho-substituted aryl iodide gave a trace amount of silylated product **2** and a much larger quantity of **3**. In short, [Rh(cod)₂]BF₄ and RhCl(CO)(PPh₃)₂ appear to be the best catalysts for producing the silylated product **2**, with almost complete conversion at room temperature in amide solvent (entries 7 and 8).¹⁵ The yield of silylated product **2** was slightly reduced at 50 °C, although the reaction time became shorter with lower catalyst loading (entries 9 and 10). In addition to K₃PO₄,¹⁶ several other bases (K₂CO₃, KOAc, and Et₃N) were tested in the protocol, but none of these yielded better results than K₃PO₄ (entries 12–14).

Next, we focused our attention on a range of possible leaving groups on the aromatic ring. As outlined in Table 2, iodide, bromide, chloride, and triflate¹⁷ were tested as leaving groups. The iodide substrates exhibited much higher reactivity than their bromide, triflate, or chloride analogues. When we examined the reaction of 2-bromoanisole with triethylsilane in the presence of an additional equal amount of tetraethylammonium iodide, the yield of silylated product was slightly increased. These results clearly indicate that the iodide anion plays a key role in suppressing the undesired reduction reaction. For further comparison, we note that our attempt to use hexamethyldisilane (Me₃SiSiMe₃) or iodotrimethylsilane (I-SiMe₃) instead of hy-

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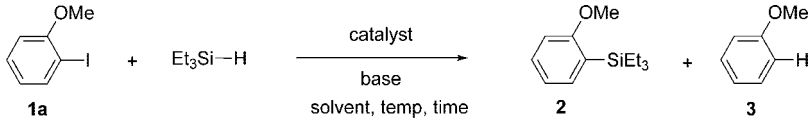
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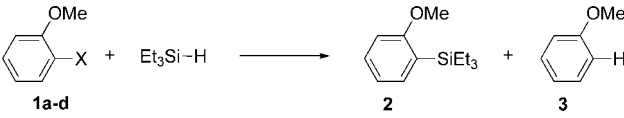
(16) K₃PO₄ was dried at 100 °C for 2 h under vacuum before use.

(17) 2-Methoxyphenyl trifluoromethanesulfonate was prepared by Ritter's method. See: Ritter, K. *Synthesis* **1993**, 735.

TABLE 1. Reaction of 2-Iodoanisole with Triethylsilane under Various Conditions^a


entry	catalyst	base	solvent	temp	time/h	ratio ^b			yield of 2 (%)
						1a	2	3	
1 ^c	Pd(P(<i>t</i> -Bu) ₃) ₂	K ₃ PO ₄	NMP ^d	rt	5	<i>e</i>	<1	99	<i>f</i>
2	PdCl ₂ (dppf)	K ₃ PO ₄	NMP	rt	96	52	2	46	<i>f</i>
3	Pd(PCy ₃) ₃	K ₃ PO ₄	NMP	rt	96	57	<1	43	<i>f</i>
4	IrCl(CO)(PPh ₃) ₂	K ₃ PO ₄	NMP	rt	96	75	<i>e</i>	25	<i>f</i>
5	RhCl(PPh ₃) ₃	K ₃ PO ₄	NMP	rt	96	1	2	97	<i>f</i>
6	[RhCl(nbd)] ₂	K ₃ PO ₄	NMP	rt	96	<i>e</i>	41	59	32
7	RhCl(CO)(PPh₃)₂	K₃PO₄	NMP	rt	96	<i>e</i>	96	4	88
8	[Rh(cod)₂]BF₄	K₃PO₄	NMP	rt	96	<i>e</i>	96	4	91
9 ^c	RhCl(CO)(PPh ₃) ₂	K ₃ PO ₄	NMP	50 °C	10	<1	89	11	83
10 ^c	[Rh(cod) ₂]BF ₄	K ₃ PO ₄	NMP	50 °C	10	<i>e</i>	84	16	81
11	[Rh(cod) ₂]BF ₄	none	NMP	rt	96	28	<i>e</i>	72	<i>f</i>
12	[Rh(cod) ₂]BF ₄	K ₂ CO ₃	NMP	rt	96	36	59	5	40
13	[Rh(cod) ₂]BF ₄	Et ₃ N	NMP	rt	96	25	60	15	49
14	[Rh(cod) ₂]BF ₄	KOAc	NMP	rt	96	2	94	4	82
15	RhCl(CO)(PPh ₃) ₂	K ₃ PO ₄	DMF	rt	96	<i>e</i>	53	47	50
16	[Rh(cod) ₂]BF ₄	K ₃ PO ₄	THF	rt	96	3	60	37	54
17	[Rh(cod) ₂]BF ₄	K ₃ PO ₄	toluene	rt	96	61	4	35	<i>f</i>

^a Reaction conditions: 2-iodoanisole (0.5 mmol), triethylsilane (1.0 mmol), catalyst (0.025 mmol), base (1.5 mmol), and solvent (1.0 mL). ^b The ratio was determined by GC analysis of the crude reaction mixture. ^c The reaction was carried out in the presence of 1 mol % of catalyst. ^d NMP: *N*-methylpyrrolidinone. ^e No detection. ^f The silylated product could not be isolated by column chromatography.

TABLE 2. Electrophile Compatibility^a


entry	X	additive	time/d	ratio ^b			yield of 2 (%)
				1a-d	2	3	
1	I (1a)	<i>c</i>	4	<i>d</i>	96	4	91
2	Br (1b)	<i>c</i>	20	<1	51	49	48
3	Br (1b)	Et ₃ Ni	20	<i>d</i>	60	40	60
4	Cl (1c)	<i>c</i>	20	88	<i>d</i>	12	<i>e</i>
5	OTf (1d)	<i>c</i>	20	54	<i>d</i>	46	<i>e</i>

^a Reaction conditions: aryl (pseudo)halide (0.5 mmol), triethylsilane (1.0 mmol), [Rh(cod)₂]BF₄ (0.025 mmol), K₃PO₄ (1.5 mmol), and NMP (1.0 mL) at rt. ^b The ratio was determined by GC analysis. ^c No additive. ^d No detection. ^e The silylated product could not be isolated.

drosilane in the coupling reaction under similar conditions resulted in failure, giving complete recovery of aryl iodide, demonstrated by GC-MS measurements.¹⁸

As summarized in Table 3, various aryl halides substituted with electron-donating or electron-withdrawing groups were converted to the corresponding arylsilyl ethers with good to high yields when the reactions were performed under optimized conditions. In all cases, the reduction of the Ar-I bonds occurred as a side reaction to produce volatile aromatic compounds, as revealed by GC-MS analysis.

(18) Transition metal-catalyzed silylations of aryl halides with disilanes in the presence of fluoride anion as activator or at high temperature have been reported. For example, see: (a) McNeill, E.; Barder, T. E.; Buchwald, S. L. *Org. Lett.* **2007**, *9*, 3785. (b) Goossen, L. J.; Ferwanah, A.-R. S. *Synlett* **2000**, 1801. (c) Shirakawa, E.; Kurahashi, T.; Yoshida, H.; Hiyama, T. *Chem. Commun.* **2000**, 1895. (d) Hatanaka, Y.; Hiyama, T. *Tetrahedron Lett.* **1987**, *28*, 4715. (e) Eaborn, C.; Griffiths, R. W.; Pidcock, A. J. *Organomet. Chem.* **1982**, *225*, 331. (f) Babin, P.; Bennetau, B.; Theurig, M.; Dunogues, J. J. *Organomet. Chem.* **1993**, *446*, 135. (g) Matsumoto, H.; Nagashima, S.; Yoshihiro, K.; Nagai, Y. *J. Organomet. Chem.* **1975**, *85*, C1. (h) Azarian, D.; Dua, S. S.; Eaborn, C.; Walton, D. R. M. *J. Organomet. Chem.* **1976**, *117*, C55.

In the reactions of aryl iodides containing electron-donating groups on the aromatic ring, the desired silanes were successfully obtained with good to high yields (entries 1–26).^{19,20} Conversely, the presence of an electron-withdrawing group bound to an arene ring slightly reduced the yield of the silylated product (entries 32, 33, 35, 36, 38, 39, 41, and 42). The presence of amino (–NH₂), hydroxy (–OH), ester (–CO₂Et),^{21,22} cyano (–CN),²² or acetyl (–COCH₃)²² functionalities on the aromatic ring was tolerated in this reaction (entries 18–23, 32, 33, 35, 36, 41, and 42). In the traditional methods of Grignard or with organolithium reagents, the protection of these functional groups is frequently required. Thus, our protocol is particularly useful for the preparation of functionalized arylsilyl ethers. Furthermore, sterically hindered ortho-substituted aryl iodides were also effectively coupled with hydrosilanes without difficulty, in sharp contrast to palladium-catalyzed silylation (entries 1–3, 9, 12, 14, 17, 18, 21, 24–26, and 29), although the larger alkyl group resulted in a reduced yield of the silylated product (*t*-Bu, ²³ 0% > *i*-Pr, 68% > Et, 79% > Me, 99%). Unfortunately, attempts at the silylation of ortho-substituted electron-deficient aryl iodides were unsuccessful (entries 28, 31, 34, 37, and 40).²⁴ We also examined the effects of other hydrosilanes under similar

(19) 3-Iodo-*N,N*-dimethylaniline and 4-iodo-*N,N*-dimethylaniline were prepared from 3-iodoaniline and 4-iodoaniline, respectively, by reductive methylation with formaldehyde and NaBH₃CN in the presence of acetic acid. (a) Borch, R. F.; Hassid, A. I. *J. Org. Chem.* **1972**, *37*, 1673. (b) Jian, H.; Tour, J. M. *J. Org. Chem.* **2003**, *68*, 5091. (c) Giumanani, A. G.; Chiavari, G.; Musiani, M. M.; Rossi, P. *Synthesis* **1980**, *9*, 743. (d) Raepffel, S.; Toussaint, D.; Suffert, J. *Synlett* **1998**, 537.

(20) 2-Iodo-*N,N*-dimethylaniline was prepared from 2-iodoanisole by methylation with iodomethane in the presence of K₂CO₃. Bunnett, J. F.; Mitchell, E.; Galli, C. *Tetrahedron* **1985**, *41*, 4119.

(21) Murata et al. reported the reaction of ethyl 4-iodobenzoate with triethylsilane in DMF at 80 °C in the presence of [Rh(cod)(MeCN)₂]BF₄ to produce the corresponding silylated product with a 53% GLC yield. See ref 8a.

(22) Quite recently, Iizuka and Kondo reported the triethylsilylation of 4-iodobenzonitrile, 4-iodoacetophenone, and methyl 4-iodobenzoate using triethylsilane in the presence of Pd(OAc)₂ as catalyst. The yields of the triethylsilylated products were 46%, 38%, and 35%, respectively. See 12d.

TABLE 3. Scope of Rhodium-Catalyzed Silylation with Aryl Iodides with Hydrosilanes^a

entry	R	R ₃ '	catalyst ^b	solvent ^c	time/d	product	yield (%)
1	2-MeO	Et ₃	A	NMP	4	2-MeOC ₆ H ₄ SiEt ₃ (2)	91
2	2-MeO	Ph ₃	A	NMP	4	2-MeOC ₆ H ₄ SiPh ₃ (4)	99
3	2-MeO	PhMe ₂	A	NMP	7	2-MeOC ₆ H ₄ SiMe ₂ Ph (5)	69
4	3-MeO	Et ₃	A	NMP	4	3-MeOC ₆ H ₄ SiEt ₃ (6)	78
5	4-MeO	Et ₃	A	NMP	4	4-MeOC ₆ H ₄ SiEt ₃ (7)	99
6	4-MeO	<i>i</i> -Pr ₃	A	NMP	4	4-MeOC ₆ H ₄ Si- <i>i</i> -Pr ₃ (8)	83
7	4-MeO	<i>t</i> -BuMe ₂	A	NMP	4	4-MeOC ₆ H ₄ Si- <i>t</i> -BuMe ₂ (9)	99
8	4-MeO	Ph ₂ Me	A	NMP	4	4-MeOC ₆ H ₄ SiPh ₂ Me (10)	98
9	2-Me ₂ N	Et ₃	B	DMI	30	2-Me ₂ NC ₆ H ₄ SiEt ₃ (11)	37
10	3-Me ₂ N	Et ₃	B	NMP	4	3-Me ₂ NC ₆ H ₄ SiEt ₃ (12)	81
11	4-Me ₂ N	Et ₃	A	NMP	4	4-Me ₂ NC ₆ H ₄ SiEt ₃ (13)	69
12	2-MeS	Et ₃	A	NMP	7	2-MeSC ₆ H ₄ SiEt ₃ (14)	99
13	4-MeS	Et ₃	B	TMU	4	4-MeSC ₆ H ₄ SiEt ₃ (15)	75
14	2-Me	Et ₃	A	NMP	4	2-MeC ₆ H ₄ SiEt ₃ (16)	99
15	3-Me	Et ₃	A	NMP	4	3-MeC ₆ H ₄ SiEt ₃ (17)	74
16	4-Me	Et ₃	A	NMP	4	4-MeC ₆ H ₄ SiEt ₃ (18)	91
17	2,4-Me ₂	Et ₃	A	NMP	4	4-MeC ₆ H ₄ SiEt ₃ (19)	76
18	2-HO	Et ₃	A	NMP	4	2-HOC ₆ H ₄ SiEt ₃ (20)	99
19	3-HO	Et ₃	A	NMP	4	3-HOC ₆ H ₄ SiEt ₃ (21)	99
20	4-HO	Et ₃	A	NMP	4	4-HOC ₆ H ₄ SiEt ₃ (22)	80
21	2-H ₂ N	Et ₃	A	NMP	4	2-H ₂ NC ₆ H ₄ SiEt ₃ (23)	99
22	3-H ₂ N	Et ₃	A	NMP	4	3-H ₂ NC ₆ H ₄ SiEt ₃ (24)	98
23	4-H ₂ N	Et ₃	A	NMP	4	4-H ₂ NC ₆ H ₄ SiEt ₃ (25)	99
24	2-Et	Et ₃	A	NMP	7	2-EtC ₆ H ₄ SiEt ₃ (26)	79
25	2-Et	Ph ₃	A	NMP	7	2-EtC ₆ H ₄ SiPh ₃ (27)	93
26	2- <i>i</i> -Pr	Et ₃	B	DMA	7	2- <i>i</i> -PrC ₆ H ₄ SiEt ₃ (28)	68
27	2- <i>t</i> -Bu	Et ₃	A	NMP	10	-	<i>d</i>
28	2-Ph	Et ₃	A	NMP	10	-	<i>d</i>
29	1-C ₁₀ H ₇	Et ₃	B	DMA	7	1-C ₁₀ H ₇ SiEt ₃ (29)	89
30	2,4,6-Me ₃	Et ₃	A	NMP	10	-	<i>d</i>
31	2-EtO ₂ C	Et ₃	A	NMP	10	-	<i>d</i>
32	3-EtO ₂ C	Et ₃	A	NMP	4	3-EtO ₂ CC ₆ H ₄ SiEt ₃ (30)	77 ^e
33	4-EtO ₂ C	Et ₃	B	NMP	4	4-EtO ₂ CC ₆ H ₄ SiEt ₃ (31)	68 ^e
34	2-MeCO	Et ₃	A	NMP	10	-	<i>d</i>
35	3-MeCO	Et ₃	A	NMP	4	3-MeCOC ₆ H ₄ SiEt ₃ (32)	83 ^e
36	4-MeCO	Et ₃	A	NMP	4	4-MeCOC ₆ H ₄ SiEt ₃ (33)	57 ^e
37	2-CF ₃	Et ₃	A	NMP	10	-	<i>d</i>
38	3-CF ₃	Et ₃	B	NMP	4	3-CF ₃ C ₆ H ₄ SiEt ₃ (34)	72 ^e
39	4-CF ₃	Et ₃	B	NMP	4	4-CF ₃ C ₆ H ₄ SiEt ₃ (35)	51 ^e
40	2-NC	Et ₃	A	NMP	10	-	<i>d</i>
41	3-NC	Et ₃	A	NMP	4	3-NCC ₆ H ₄ SiEt ₃ (36)	72 ^e
42	4-NC	Et ₃	B	NMP	4	4-NCC ₆ H ₄ SiEt ₃ (37)	53 ^e
43	H	<i>n</i> -Pr ₃	A	NMP	4	C ₆ H ₅ Si- <i>n</i> -Pr ₃ (38)	89

^a Reaction was performed with aryl iodide (0.5 mmol), hydrosilane (1.0 mmol), K₃PO₄ (1.5 mmol), and rhodium catalyst (5 mol %) in solvent (1.0 mL) at rt. ^b A: [Rh(cod)₂]BF₄, B: RhCl(CO)(PPh₃)₂. ^c NMP: *N*-methylpyrrolidinone; DMI: *N,N*-dimethylimidazolidinone; TMU: *N,N,N',N'*-tetramethylurea; DMA: *N,N*-dimethylacetamide. ^d No detection. ^e Aryl iodide (0.5 mmol), hydrosilane (0.6 mmol), K₃PO₄ (1.5 mmol), and rhodium catalyst (5 mol %) in solvent (1.0 mL).

reaction conditions (entries 2, 3, 6–8, 25, and 43). This rhodium-catalyzed silylation was also practical at a 20 mmol scale, without deleterious effects.²⁵

We continued our investigation by exploring the reaction of tertiary silanes with heteroaryl iodides. The scope of the silylation was explored by using heteroaryl iodides, as outlined in Table 4. Different heteroaryl iodides, such as thiophene and pyridine derivatives, were successfully coupled to triethylsilane under the same reaction conditions to produce the desired

compounds with good yields (entries 1 and 2). It should also be noted that coupling diiodo- and triiodobenzene to triphenylsilane produced the oligoarylsilanes with good yields in this catalytic system (entries 4–6). Thus, the present reactions offer a convenient method for directly synthesizing oligoarylsilanes, which have wide applications in material science, from di- and triiodoaromatics. As another application of this work, we found that it is possible to efficiently couple vinyl and alkynyl iodide to hydrosilane under conditions similar to those used for the corresponding aryl compounds (entries 7 and 8).²⁶ This type of compound has been the focus of considerable interest, notably


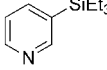

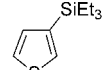

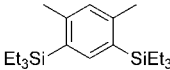
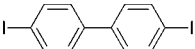
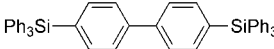
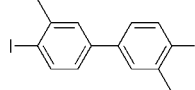
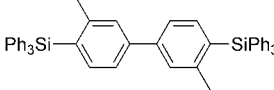
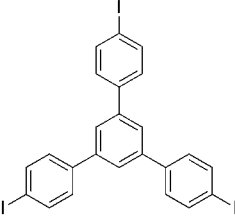
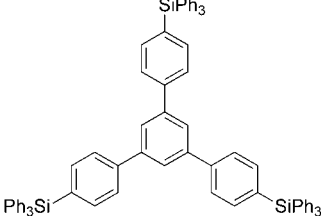

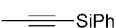




(23) 2-Iodo-*tert*-butylbenzene was prepared according with a modified method based on the literature. (a) Fey, N.; Howell, J. A. S.; Lovatt, J. D.; Yates, P. C.; Cunningham, D.; McArdle, P.; Gottlieb, H. E.; Coles, S. J. *Dalton Trans.* **2006**, 5464. (b) Åkermark, B.; Ljungqvist, A. J. *Organomet. Chem.* **1978**, 149, 97.

(24) The silylation reactions with aryl iodides containing a formyl group gave unsatisfactory results because complex mixtures were obtained, resulting from the high reactivity of the aldehyde moiety. Although the silylated products could not be isolated in a pure form, the yields were estimated to be less than 10% based on GC-MS analysis of the reaction mixture.

(25) In a 20 mmol scale experiment under the reaction conditions described, the silylation shown in Table 1 entry 1 proceeded to an 85% yield.

(26) For earlier work on the palladium-catalyzed coupling of alkenyl iodides with tertiary silanes, see: Murata, M.; Watanabe, S.; Masuda, Y. *Tetrahedron Lett.* **1999**, 40, 9255.

TABLE 4. Rhodium-Catalyzed Silylation of Heteroaryl Iodides, Di- or Triiodo Aromatic Compounds, and Alkynyl-, Alkenyl-, Allyl-, and Alkyl Iodides

	R-I	+ H-SiR ₃	→ conditions	R-SiPh ₃	
entry	R-I	R ₃	conditions ^a	product	yield (%)
1		Et ₃	A	 39	71
2		Et ₃	B	 40	88
3		Et ₃	B	 41	73
4		Ph ₃	B	 42	86
5		Ph ₃	B	 43	54
6		Ph ₃	B	 44	55
7		Ph ₃	C	 45	38 ^b
8		Ph ₃	D	 46	49 ^b
9		Ph ₃	D	—	C
10		Ph ₃	A	—	C

^a Conditions: (A) R-I (0.5 mmol), HSiR₃ (2.0 equiv), K₃PO₄ (3.0 equiv), RhCl(CO)(PPh₃)₂ (5 mol %), NMP (1.0 mL), rt, 4 d. (B) R-I (0.5 mmol), HSiR₃ (2.0 equiv), [Rh(cod)₂]BF₄ (5 mol %), NMP (1.0 mL), rt, 6 d. (C) Ph₃SiH (1.0 mmol), R-I (3.0 equiv), K₃PO₄ (3.0 equiv), rt, 4 d. (D) Ph₃SiH (1.0 mmol), R-I (3.0 equiv), K₃PO₄ (3.0 equiv), 0 °C, 6 d. ^b The yield was based on the amount of triphenylsilane. No silylated product was obtained.

as a precursor to polyarylsilanes.²⁷ Disappointingly, allyl and alkyl iodides did not produce even trace amounts of the corresponding organosilane compounds (entries 9 and 10).

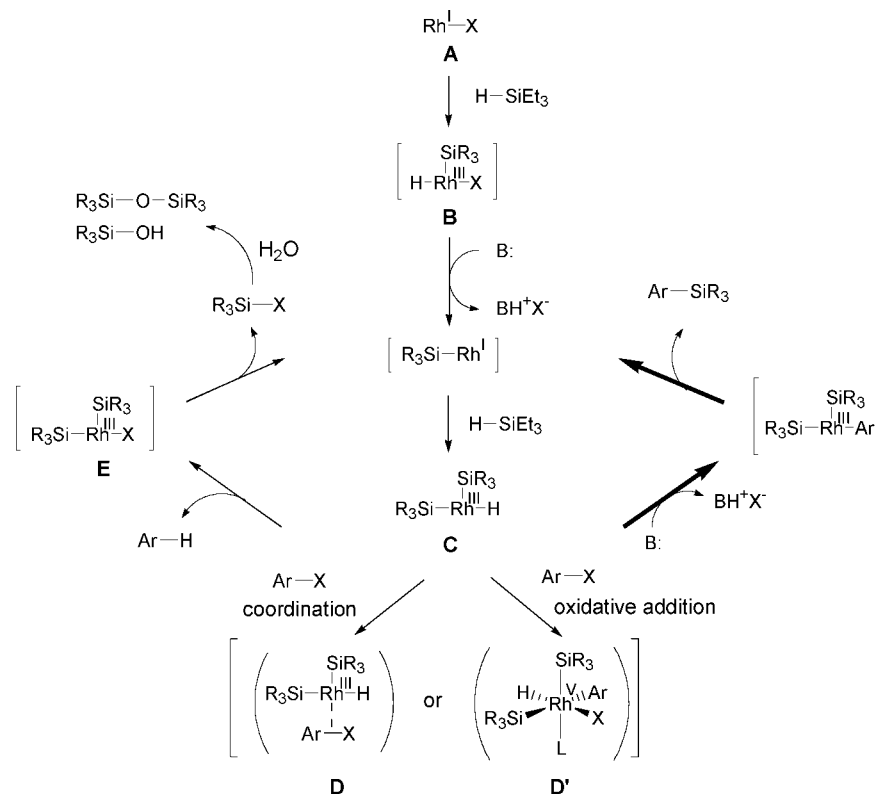
Reaction Mechanism. Rh complexes exhibit Si-H bond activation chemistry because these metals can support mononuclear silyl complexes in a variety of oxidation states.²⁸ Although several mechanisms may be considered for the

silylation reaction, we have formulated a possible mechanism for the Rh-catalyzed arylation of hydrosilane, as described in Scheme 2, based on ¹H and ²⁹Si NMR analyses during the course of the stoichiometric reaction (Rh catalyst, RhCl(CO)(PPh₃)₂; aryl halide, 4-iodoanisole; hydrosilane, H-SiEt₃ [ratio 1:1:1] in

(27) For reviews, see: (a) Langkopf, E.; Schinzer, D. *Chem. Rev.* **1995**, *95*, 1375. (b) Fleming, I.; Dunogues, J.; Smithers, R. H. *Org. React.* **1989**, *37*, 57. (c) Colvin, E. W. *Silicon Reagents in Organic Synthesis*; Academic Press: London, UK, 1988.

(28) For representative reports on the organosilane complexes of rhodium(V), see: (a) Fernandez, M.-J.; Maitlis, P. M. *J. Chem. Soc., Chem. Commun.* **1982**, 310. (b) Cook, K. S.; Incarvito, C. D.; Webster, C. E.; Fan, Y.; Hall, M. B.; Hartwig, J. F. *Angew. Chem., Int. Ed.* **2004**, *43*, 5474. (c) Fernandez, M.-J.; Bailey, P. M.; Bentz, P. O.; Ricci, J. C.; Koetzle, T. F.; Maitlis, P. M. *J. Am. Chem. Soc.* **1984**, *106*, 5458. (d) Nagashima, H.; Tatebe, K.; Ishibashi, T.; Nakaoka, A.; Sakakibara, J.; Itoh, K. *Organometallics* **1995**, *14*, 2868.

SCHEME 2. Plausible Mechanism for Rhodium-Catalyzed Silylation



DMF-*d*₇, at room temperature).²⁹ The catalytic cycle of the reaction is initiated by the reaction of the rhodium catalyst A with hydrosilane to produce a silyl metal hydride complex B. Although a hydrosilane as well as an aryl halide can be added oxidatively to Rh(I) complexes, the NMR studies indicated that the oxidative addition of hydrosilane occurred predominantly under the conditions used. Consequently, a mechanism involving the initial oxidative addition of an aryl halide can effectively be ruled out in the present reaction. The elimination of HX with the aid of a base, followed by the further oxidative addition of H-SiR₃, would produce the intermediate formulated as Rh(H)(SiR₃)₂ C,³⁰ which is the key intermediate in this transformation and has peaks at 1.00 (t) and 0.73 ppm (q) in the triethyl moiety, and -9.69 (br s) and -10.64 ppm (br s) in the hydride region. The integral ratio of the triethylsilyl moiety to the hydride region supports the structure of the intermediate.^{31,32} Only one peak at 22.0 ppm was observed by the measurement of ²⁹Si NMR,³³ which supports the existence of a stable intermediate during the catalysis. K₃PO₄ is essential for the formation of intermediate C. As the reaction progresses, the coordination or oxidative addition of aryl halide to intermediate C takes place to produce the Rh(III) intermediate D or the Rh(V) intermediate D'. In the presence of base, the rapid base-promoted reductive elimination of HX, the subsequent reductive elimination of Ar-SiR₃, and the oxidative addition of H-SiR₃ dominates, to

generate intermediate C. In this case, another cycle that produces the reduced product is competitive with this route, producing catalyst C through intermediate E, and steric and electronic factors have a significant effect on this step.³⁴⁻³⁶ The signals of 9.1 and 13.4 ppm in the ²⁹Si NMR spectra, corresponding to the Et₃SiOSiEt₃ and Et₃SiOH, appeared as the reaction proceeded, and we believe that Et₃SiOSiEt₃ and Et₃SiOH are the compounds most likely to have been formed via the hydrolysis

(29) For ¹H and ²⁹Si NMR spectra, see the Supporting Information.

(30) (a) Sun et al. reported the intermediate "(Ph₃P)₂Rh(H)(SiEt₃)₂" in the hydrosilylation of cyclopropyl ketones, see: Sun, C.; Tu, A.; Slough, G. A. *J. Organomet. Chem.* **1999**, 582, 235. (b) Osakada et al. reported "cyclic *fac*-[Rh(SiMe₂CH₂CH₂SiMe₂H(PMe₃)₃)] prepared in situ from RhCl(PMe₃)_n and NaSPh with Me₂HSiCH₂CH₂SiHMe₂, see: Osakada, K.; Hataya, K.; Nakamura, Y.; Tanaka, M.; Yamamoto, T. *J. Chem. Soc. Chem. Commun.* **1993**, 576.

(31) The integral ratio of δ 1.00 (-CH₃)/hydride region (Rh-H) was 18/1. Because of the overlapping peaks, the integration of the methylene group could not be determined.

(32) 4-Iodoanisole was not completely reacted under the stoichiometric conditions. To complete the reaction, more than 2 equiv of triethylsilane for rhodium catalyst was necessary from the NMR studies. This result also provides some support for the existence of Rh(H)(SiEt₃)₂ as a key intermediate.

(33) For representative ²⁹Si NMR data of rhodium(III) silyl complexes, see: (a) CpRh(C₂H₄)(SiEt₃)(H) 41.6 ppm: Duckett, S. B.; Haddleton, D. M.; Jackson, S. A.; Perutz, R. N.; Paliakoff, M.; Upmacis, R. K. *Organometallics* **1988**, 7, 1526. (b) CpRh(Si(*i*-Pr)₃)(C₂H₄)(H) 49.3 ppm: Duckett, S. B.; Perutz, R. N. *Organometallics* **1992**, 11, 90. (c) *mer*-RhCl(H)(SiHPh₂)(PMe₃)₃ 14.9 ppm: Osakada, K.; Sarai, S.; Koizumi, T.; Yamamoto, T. *Organometallics* **1997**, 16, 3973. (d) RhCl(H)(Si(OEt)₂Me)(PPh₃)₃ 15.4 ppm: Nishihara, Y.; Takemura, M.; Osakada, K. *Organometallics* **2002**, 21, 825. (e) *fac*-Tris[(8-quinolyl)dimethylsilyl]rhodium(III) 23.6 ppm: Djurovich, P. I.; Safir, A. L.; Keder, N. L.; Watts, R. J. *Inorg. Chem.* **1992**, 31, 3195.

(34) Recently, Tilley and co-workers studied the reaction of chlorobenzene with triethylsilane in the presence of a rhodium complex bearing chelating nitrogen-based ligands. They pointed out the Rh(V) intermediates in the catalytic process. See ref 12e.

(35) Okazaki et al. reported that the reaction of the (2-phosphinoethyl)silyl rhodium(I) complex with excess PhMe₂SiH proceeded spontaneously at rt to give the dihydrido rhodium(III) complex and (PhMe₂Si)₂ through a rhodium(V) intermediate. See: Okazaki, M.; Ohshitani, S.; Tobita, H.; Ogino, H. *Chem. Lett.* **2001**, 952.

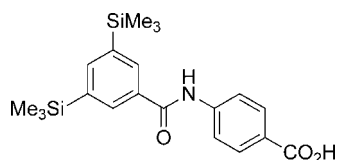
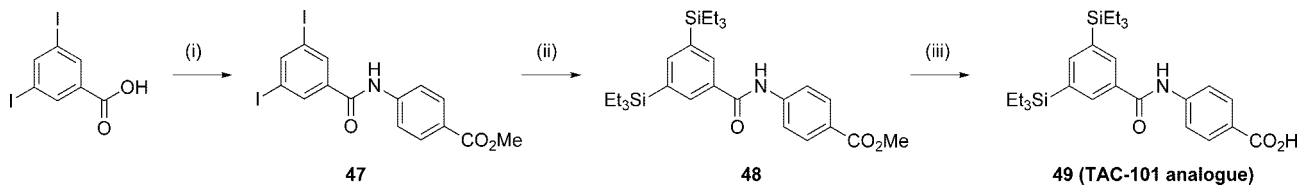


FIGURE 1. Structure of TAC-101.

SCHEME 3. Application of the Rh-Catalyzed Si–C Bond Formation to the Synthesis of TAC-101 Analogue^a

^a Reagents and conditions: (i) 4-H₂NC₆H₄CO₂Me, EDC-HCl, Et₃N, HOBt, DMF, 50 °C, 2 d, 81%; (ii) [Rh(cod)₂]BF₄ (5 mol%), Et₃SiH, DMPU, rt, 4 d, 68%; (iii) aqueous NaOH/EtOH, rt, 1 d, 99%.

of Et₃SiX.^{37–39} Although there was a possibility of the generation of hexaethyldisilane as a side product, the peak derived from disilane compound (–20 ppm) was not observed by ²⁹Si NMR during the catalysis.

Application. To demonstrate the utility of these reactions, we undertook the short-step synthesis of a TAC-101 (4-[[[3,5-bis(trimethylsilyl)phenyl]carbonyl]amino]benzoic acid) analogue, which is a synthetic retinobenzoic acid with selective binding affinity for RAR-α (Figure 1).¹³ Kagechika and Shudo et al. have reported a synthetic process for the preparation of TAC-101 in five steps using 1,3,5-tribromobenzene as the starting material (total 3.4% yield). We have now developed a new synthetic route for the TAC-101 derivative in three steps, using the present Rh-catalyzed arylation of hydrosilane as a key step, starting from 3,5-diiodobenzoic acid. The synthesis is outlined in Scheme 3. Thus, 3,5-diiodobenzoic acid and methyl 4-aminobenzoate were treated with 1-ethyl-3-(3-dimethylaminopropyl)-carbodiimide hydrochloride (EDC-HCl) at 50 °C to produce the corresponding amide product **47** with an 81% yield. The introduction of trialkylsilyl groups with triethylsilane to the aromatic ring using the rhodium catalyst proceeded smoothly in DMPU (1,3-dimethyl-3,4,5,6-tetrahydro-2(1*H*)-pyrimidinone) at room temperature to produce the corresponding bistrimethylsilylated product **48** with a 68% yield.⁴⁰ The hydrolysis of the ester group was performed with NaOH to produce the TAC-101 derivative **49** with an almost quantitative yield. This new arylation reaction is a straightforward method for the preparation of an RAR-α-selective agonist for use in the treatment of liver cancer.

Conclusion

In summary, we have developed a general method for the silylation of aryl halides using tertiary silanes as the silylating reagent. A variety of substrates with different functional groups (electron-withdrawing and electron-donating groups) in para, meta, and ortho positions were successfully coupled in the presence of K₃PO₄ and a rhodium catalyst. The scope of the potential substrates is broader than those of palladium-catalyzed

silylation, which we reported previously. The reactivity order of aryl halides was Ar–I > Ar–Br > Ar–Cl, Ar–OTf, and the effects of the substituent groups on the aromatic rings of the aryl halides were electron-donating > electron-withdrawing. In the case of aryl bromide, the yield of silylated product was slightly increased by treatment with an additional equal amount of tetraethylammonium iodide. By using this reaction as the key step, a concise synthesis of a pharmaceutical was achieved. The importance of Rh(H)(SiR₃)₂ as the key catalytic species and the reaction mechanism were discussed based on the results of ¹H and ²⁹Si NMR measurements during the catalysis. It is anticipated that these new reactions will begin to replace the use of aryl organometallics in the synthesis of tetraorganosilanes and that this new reactivity will facilitate the design of other catalytic Si–H bond functionalities. Further applications of this method to the preparation of other useful organosilane products are currently under investigation.

Experimental Section

All the experiments were carried out under an argon atmosphere in oven-dried glassware. Unless otherwise noted, the tertiary silanes and aryl halides were purchased from commercial sources and used without purification.

Typical Procedure for the Rhodium-Catalyzed Silylations of Aryl (Pseudo)halides with Trialkylsilane. An oven-dried Schlenk flask with a magnetic stirring bar was charged with RhCl(CO)(PPh₃)₂ or [Rh(cod)₂]BF₄ (0.025 mmol) and K₃PO₄ (1.5 mmol) in air. Aryl (pseudo)halides (0.5 mmol) and tertiary silanes (1.0 mmol) were also added at this time if the solid form of these reagents was used. The flask was capped with a rubber septum, evacuated, and then flushed with argon. Solvent (1 mL), aryl (pseudo)halides (if a liquid, 0.5 mmol), and tertiary silanes (if a liquid, 1.0 mmol) were then added successively with a syringe, and the reaction mixture was stirred at room temperature for several days. The reaction was quenched with water when the starting material was not detected on thin-layer chromatography (TLC). The aqueous layer was extracted three times with CH₂Cl₂ and dried over Na₂SO₄. The solvent was evaporated under reduced pressure, and column chromatography on silica gel produced the pure silylated product.

(2-Methoxyphenyl)triethylsilane (2).^{11b} Colorless oil; ¹H NMR (500 MHz, CDCl₃) δ 7.36–7.32 (m, 2H), 6.94 (t, 2H, *J* = 7.2 Hz), 6.82 (d, 1H, *J* = 8.1 Hz), 3.77 (s, 3H), 0.93 (t, 9H, *J* = 7.8 Hz), 0.78 (q, 6H, *J* = 8.1 Hz); ¹³C NMR (125 MHz, CDCl₃) δ 164.5 (C_q), 136.0 (CH), 130.5 (CH), 125.1 (C_q), 120.3 (CH), 109.3 (CH), 54.8 (CH₃), 7.6 (CH₃), 3.5 (CH₂); EI-MS *m/z* 222 (M⁺).

(3-Methoxyphenyl)triethylsilane (4). Colorless oil; ¹H NMR (500 MHz, CDCl₃) δ 7.29 (t, 1H, *J* = 7.7 Hz), 7.07 (d, 1H, *J* = 7.1 Hz), 7.03 (d, 1H, *J* = 2.7 Hz), 6.89 (ddd, 1H, *J* = 8.3, 2.8, 0.9 Hz), 3.82 (s, 3H), 0.96 (t, 9H, *J* = 7.8 Hz), 0.81–0.76 (m, 6H); ¹³C NMR (125 MHz, CDCl₃) δ 158.8 (C_q), 139.2 (C_q), 128.8 (CH), 126.5 (CH), 119.9 (CH), 113.6 (CH), 55.0 (CH₃), 7.4 (CH₃), 3.3 (CH₂); EI-MS *m/z* 222 (M⁺). Anal. Calcd for C₁₃H₂₂O₂Si: C, 70.21; H, 9.97. Found: C, 70.11; H, 10.01.

(36) For reviews of Rh(V) complexes as reaction intermediates, see: (a) Marciniak, B. *Appl. Organomet. Chem.* **2000**, *14*, 527. (b) Corey, J. Y.; Braddock-Wilking, J. *Chem. Rev.* **1999**, *99*, 175.

(37) The formation of Et₃SiOSiEt₃ and Et₃SiOH was also identified by GC-MS analysis of the reaction mixture and by comparing the data with those of authentic samples.

(38) Kunai et al. reported that the reaction of trialkylsilane and alkyl or aryl iodide in the presence of palladium dichloride gave corresponding iodosilane with a good to high yield, see: Kunai, A.; Sakurai, T.; Toyoda, E.; Ishikawa, M.; Yamamoto, Y. *Organometallics* **1994**, *13*, 3233.

(39) As one of the referees pointed out, when we reacted Ph₃SiH in K₃PO₄ with RhCl(CO)(PPh₃)₂ in NMP (in the absence of Ar-I), Ph₃Si-O-SiPh₃ was obtained with ca. 50% conversion because of the reduction of amide to amine. The presence of *N*-methylpyrrolidine has been confirmed by GC-MS. Igarashi and Fuchikami have reported the transition-metal-complex-catalyzed reduction of amides with hydrosilanes, see: Igarashi, M.; Fuchikami, T. *Tetrahedron Lett.* **2001**, *42*, 1945.

Synthetic Procedure for TAC-101 Derivative 49. (i) To a solution of 3,5-diiodobenzoic acid⁴¹ (0.32 g, 0.86 mmol), methyl 4-aminobenzoate (0.19 g, 1.26 mmol), EDC-HCl (0.33 g, 1.72 mmol), and HOBt (0.21 g, 0.91 mmol) in DMF (4 mL) was added Et₃N (0.3 mL, 2.15 mmol) at rt under an argon atmosphere, and the mixture was stirred at 50 °C for 2 d. The reaction was quenched with sat. NaHCO₃ aqueous solution and the organic layer was separated. The aqueous layer was extracted five times with CH₂Cl₂. The combined extracts were washed with 1 M HCl and dried over Na₂SO₄, then the solvent was evaporated under reduced pressure. The residue was purified by chromatography on silica gel (eluent: hexane/EtOAc = 8/1) to produce **47** as a colorless solid (0.35 g, 81%). (ii) To a mixture of **47** (109 mg, 0.21 mmol), K₃PO₄ (365 mg, 1.72 mmol), and [Rh(cod)₂]BF₄ (11 mg, 0.025 mmol) in DMPU (1.0 mL) was added Et₃SiH (0.12 mL, 0.75 mmol) at rt under Ar. After being stirred for 4 d, the reaction was quenched with H₂O and the products were extracted five times with CH₂Cl₂. The solvent was removed under reduced pressure. Purification was by column chromatography on silica gel (eluent: hexane/EtOAc = 5/1) to give **48** (71 mg, 68%). (iii) To a solution of **48** (281 mg, 0.58 mmol) in EtOH (10 mL) was added 1 M NaOH solution (1.2 mL) and the reaction was monitored by TLC. The reaction was quenched with 1 M HCl to pH 3, as indicated by pH paper. The quenched reaction was extracted with CH₂Cl₂ five times and the combined extracts

(40) Because trimethylsilane is a volatile compound (bp 6.7 °C), triethylsilylated retinoid benzoic acid **49** was prepared instead of TAC-101.

(41) 3,5-Diiodobenzoic acid is commercially available from Tyger Scientific Inc. (Princeton, NJ, USA).

were dried over Na₂SO₄. The solvent was removed under reduced pressure to produce the TAC-101 analogue **49** (267 mg, 99%).

4-[[[3,5-Bis(triethylsilyl)phenyl]carbonyl]amino]benzoic acid (49). Colorless cubes (recrystallized from hexane-CH₂Cl₂); Mp 222.5–225.0 °C; ¹H NMR (500 MHz, CDCl₃) δ 8.26 (d, 2H, *J* = 8.8 Hz), 7.91 (br s, 1H), 7.81 (d, 2H, *J* = 1.0 Hz), 7.81–7.78 (m, 3H), 0.99 (t, 18H, *J* = 7.8 Hz), 0.87–0.82 (m, 12H); ¹³C NMR (125 MHz, CDCl₃) δ 171.5 (C=O), 167.1 (C=O), 144.0 (C_q), 143.0 (C_q), 137.5 (CH), 133.1 (C_q), 132.9 (CH), 131.6 (CH), 124.9 (C_q), 119.3 (CH), 7.4 (CH₃), 3.3 (CH₂); EI-MS *m/z* 469 (M⁺). Anal. Calcd for C₂₆H₃₉NO₃Si₂: C, 66.48; H, 8.37; N, 2.98. Found: C, 66.30; H, 8.33; N, 2.98.

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Supporting Information Available: Compound characterization data, copies of the ¹H and ¹³C NMR spectra, and the ¹H and ²⁹Si NMR spectra used to monitor the reactions. This material is available free of charge via the Internet at <http://pubs.acs.org>.

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